



UNC CHARLOTTE



CHARLOTTE RESEARCH INSTITUTE

3RD ANNUAL CRI CONFERENCE

“Nanoimprint Technologies and
Applications in Photonics”

June 19-22, 2006

UNC Charlotte

The purpose of this workshop is to focus on nanoimprint technologies for the low-cost replication of optical components from microlenses to photonic crystal circuits. The meeting will bring together a number of internationally known leaders in this field to assess the state of the art in nanoimprint techniques, the relative merits of different approaches and the fundamental challenges that remain to be addressed in utilizing this technology, particularly in photonics. We will also be bringing together researchers and prospective industry users of this technology.

For further details, please contact:
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*Planned demonstration on
UNC Charlotte's Imprio 100
Nanoimprint Lithography System*

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